

Transaction Information

Tool ID	DFRN718
Tool Status	Running Wafers
Location	Singapore
Wafer Size	300 mm
Fab Section	Diffusion
Tool Available Date	2025-02-28

General Product Information

Vendor Supplier	TEL
Model	TEL FORMULA-1S-H
Vintage	2010
Serial No	P00001055059
Asset Description	LPCVD Nitride with In-situ clean furnace
Software Version	V2.12 Rev.R000 [F00B00-0000F]
CIM	SECS
Process	LPCVD Nitride with In-situ clean

Hardware Configuration

System Type	Description	Quantity	Status
Main System	TEL Formula furnaces with in-situ clean	1	OK
Options System	RCU	1	OK
Others	Power Box	1	OK
Handler System	TEL Formula Robot		OK
Factory Interface	FOUP	2	OK
Others	Gas Detector	1	OK

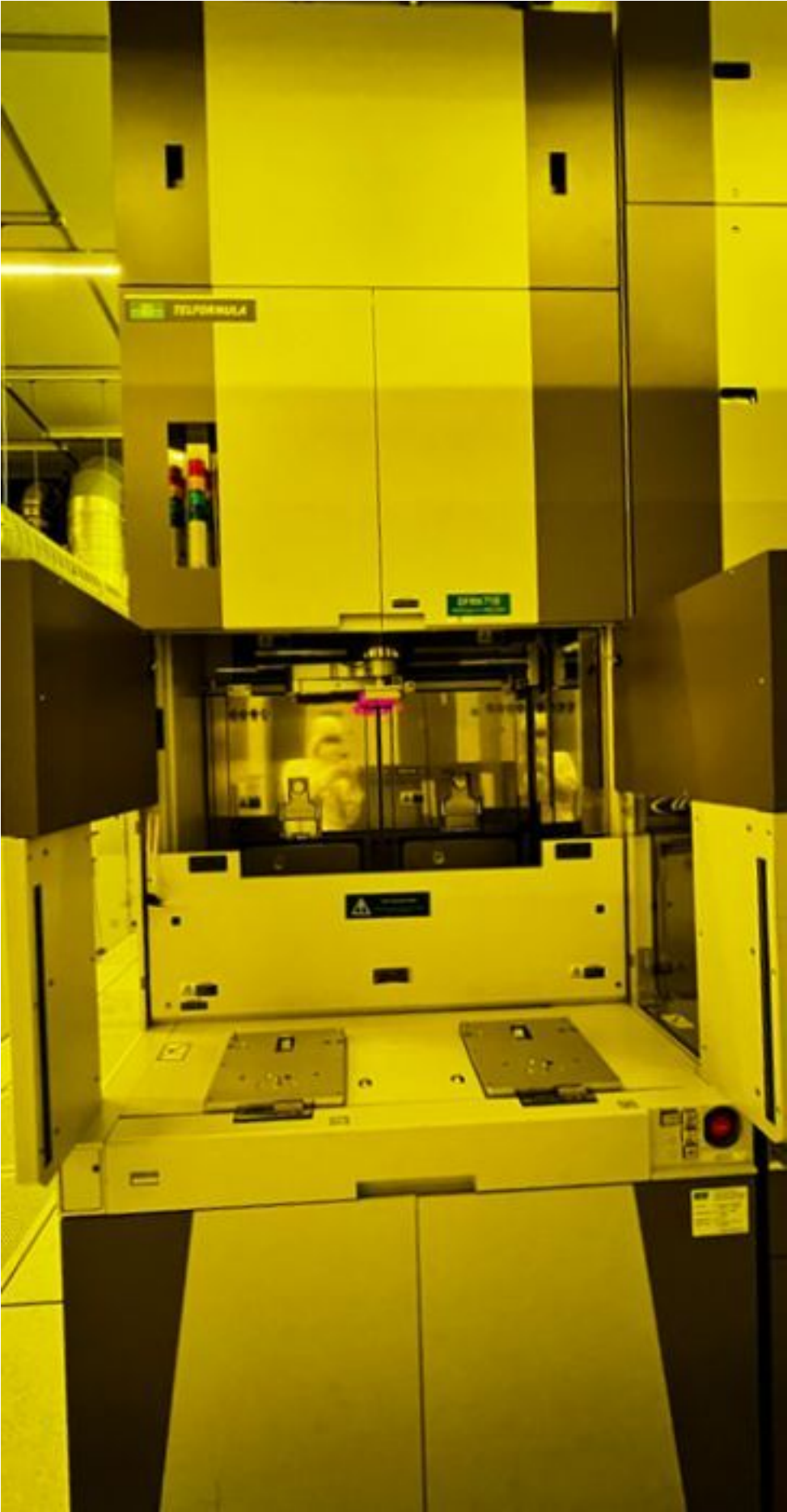
Excluded Items List (Pumps, Chillers & Abatement are all excluded)

Description	Quantity
Nil	

* List above may or may not be comprehensive. Tool is sold in "as-is" condition. To ensure your satisfaction, we strongly recommend to make an appointment to inspect this and every tool you are interested in.

Tool Pictures

General	TEL Formula
---------	-------------













Manufacture Serial

P00001055059

